



### **Science Arts & Métiers (SAM)**

is an open access repository that collects the work of Arts et Métiers Institute of Technology researchers and makes it freely available over the web where possible.

This is an author-deposited version published in: <https://sam.ensam.eu>  
Handle ID: [.http://hdl.handle.net/10985/22700](http://hdl.handle.net/10985/22700)

#### **To cite this version :**

Daisuke SAYA, Denis DEZEST, Aaron J WELSH, Fabrice MATHIEU, Olivier THOMAS, Thierry LEICHLÉ, Susan TROLIER-MCKINSTRY, Liviu NICU - Piezoelectric nanoelectromechanical systems integrating microcontact printed lead zirconate titanate films - Journal of Micromechanics and Microengineering - Vol. 30, n°3, p.035004 - 2020

Any correspondence concerning this service should be sent to the repository

Administrator : [scienceouverte@ensam.eu](mailto:scienceouverte@ensam.eu)



# Piezoelectric nanoelectromechanical systems integrating microcontact printed lead zirconate titanate films

Daisuke Saya<sup>1</sup>, Denis Dezest<sup>1</sup>, Aaron J Welsh<sup>2</sup>, Fabrice Mathieu<sup>1</sup>, Olivier Thomas<sup>3</sup>, Thierry Leïchlé<sup>1</sup>, Susan Trolier-McKinstry<sup>2</sup> and Liviu Nicu<sup>1</sup>

<sup>1</sup> LAAS-CNRS, University of Toulouse, 7 Avenue du Colonel Roche, 31077 Toulouse, France

<sup>2</sup> Department of Materials Science and Engineering and Materials Research Institute, The Pennsylvania State University, N-227 Millennium Science Complex, University Park, PA 16802, United States of America

<sup>3</sup> Arts et Métiers, Laboratoire des Sciences de l'Information et des Systèmes (LISPEN EA 7515), 8 boulevard Louis XIV 59046 Lille, France

E-mail: [dsaya@laas.fr](mailto:dsaya@laas.fr)

## Abstract

A piezoelectric nanoelectromechanical system (NEMS) with integrated actuation and detection capabilities was fabricated using lead zirconate titanate (PZT) thin films patterned by microcontact printing. PZT-coated cantilever resonators of various dimensions were fabricated to assess the variability in PZT properties as a function of the device dimensions; the microcontact-printed PZT was 281 nm thick. PZT layers of the cantilevers were poled at  $107 \text{ kV cm}^{-1}$  and  $150 \text{ }^\circ\text{C}$  to improve their piezoelectric properties. It was demonstrated that PZT piezoelectrics can be utilized for simultaneous actuation and detection of resonance. The PZT cantilevers were analytically modelled to estimate values of their piezoelectric coefficient  $d_{31}$ . Mechanical tip displacement detection of the cantilevers by laser vibrometer was also carried out to validate the estimation of  $d_{31}$ .

Keywords: nanoelectromechanical systems, piezoelectricity, PZT film, microcontact printing

(Some figures may appear in colour only in the online journal)

## 1. Introduction

Over the last decade, advances in nanofabrication technology and electromechanical systems have led to the emergence of nanoelectromechanical systems (NEMS). NEMS-based resonators have significantly enhanced device performance through size reduction [1–12]. Specifically, mechanical resonators with free-standing structures of nanometer scale cantilevers or bridges have high sensitivities for mass sensing applied to gas [4, 5] and biomolecule [6, 7] detection. NEMS structures are fabricated two ways; bottom-up fabrication produces nanoresonators with potentially smaller sizes and thus higher sensitivities in mass detection [4, 5], top-down

fabrication techniques enable mass production and integration with electrical circuits [6–12].

Piezoelectric films, which translate mechanical energy into electrical and vice versa, have widely been used for microelectromechanical systems (MEMS) transduction, i.e. actuation and detection [9–21]. Of the various transduction mechanisms used in MEMS devices, piezoelectricity requires relatively low actuation voltage and offers the possibility of sensing, resulting in integrated devices that are compact, and thus potentially portable [13–16, 20, 21]. In this regard, piezoelectric films could be particularly advantageous for transduction in NEMS, since there are few solutions suited to both actuation and sensing at this scale. However, studies have

shown that some sputtered PZT films on NEMS resonators displayed reduced performance [17, 18], likely as a result of a deterioration of the films' piezoelectric characteristics with reduced thickness. Recently, microcontact printed PZT films were found to retain their characteristics with reduced lateral dimensions and thicknesses [19, 20]. Our group has already fabricated cantilevers with microcontact printed PZT films and has verified simultaneous actuation and detection capability [20]. In this work, more cantilevers geometries have been explored which allows the role of dimension on the  $d_{31}$  value to be assessed.

The aim of this work is thus to prove that microcontact printed PZT films are good candidates for efficient NEMS transduction. For this, silicon cantilevers of various dimensions integrating microcontact printed PZT thin film were fabricated and characterized. The PZT cantilevers were assessed for piezoelectric excitation and detection. The effect of poling on the piezoelectric characteristics of the PZT was investigated. Then, the PZT cantilevers were analytically modeled as laminated beams for estimations of their piezoelectric coefficient  $d_{31}$ , with a measure of the electrical charge created in the piezoelectric layer for a given excitation voltage around a given resonance. This method was also validated by resonance measurements by means of a laser vibrometer.

## 2. Fabrication of silicon cantilevers with microcontact printed PZT film

Fabrication of PZT-coated cantilevers was carried out using SOI (silicon on insulator) wafers with a 340 nm top Si layer, 1  $\mu\text{m}$  thick buried  $\text{SiO}_2$  and a 525  $\mu\text{m}$  thick bulk Si handle wafer. An ultraviolet (UV) stepper photo repeater (I-line FPA 3000 Canon Inc.) was used for all lithography steps since high resolution and precise alignments were desirable for top-down NEMS fabrication.

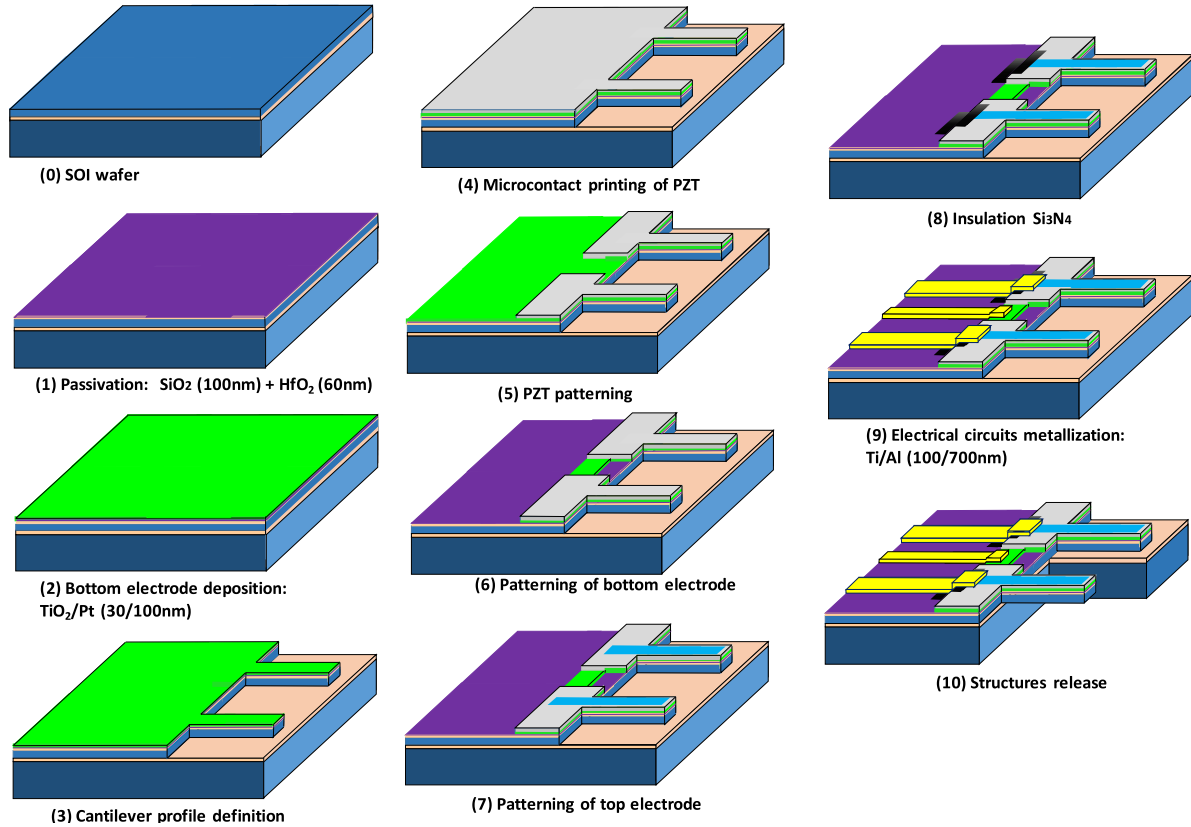
First, a 100 nm thick  $\text{SiO}_2$  film was grown by thermal oxidation and a 60 nm thick hafnium dioxide ( $\text{HfO}_2$ ) film was deposited by atomic layer deposition (ALD) to create a barrier against Pb diffusion (figure 1(1)). The deposition occurred at 200  $^\circ\text{C}$  with a chamber pressure of 0.72 Torr. The reactant pulse time for  $\text{H}_2\text{O}$  and tetrakis(ethylmethylamino) hafnium (TEMAH) was 0.03 and 0.15 s respectively, with a purge time of 10 s between each pulse. These cycles were repeated 619 times to create an amorphous 60 nm thick  $\text{HfO}_2$  layer which was crystallized with a 700  $^\circ\text{C}$  heat treatment in an  $\text{O}_2$  ambient for 1 min. A 30 nm titanium adhesion layer was sputtered at room temperature using a power of 200 W, a bias of 460 V, a current of 0.47 A, a deposition pressure of 2 mTorr, and an Ar flow rate of 8 sccm, for 300 s. Without breaking vacuum, a 125 nm Pt bottom electrode was sputtered at room temperature using a power of 200 W, a bias of 580 V, a current of 0.34 A, a deposition pressure of 2.5 mTorr, and an Ar flow rate of 11 sccm, for 417 s (figure 1(2)). Next, the cantilever was defined by reactive ion etching (RIE). For this purpose, after patterning a photoresist layer with the stepper, a 540 nm nickel layer to be used as the hard mask during ion etching was deposited by electroplating. Successive reactive ion etching of Pt, Ti,  $\text{HfO}_2$ ,  $\text{SiO}_2$  and top Si layer was

performed until reaching the buried  $\text{SiO}_2$  layer (figure 1(3)). Then, the nickel hard mask was removed using the nickel etchant TFB (Nitric acid aqueous solution). Microcontact printing of the PZT film was then performed on top of the electrode patterned on the silicon structure (figure 1(4)). For printing, a PZT sol-gel solution (1% Mn doped, with atomic percentage Pb = 110%, Zr = 30%, Ti = 70%, Mn = 1%), from Mitsubishi Materials was spin-coated onto a polydimethylsiloxane (PDMS) stamp with a polyurethane layer that improved wetting of the PZT solution [19]. The PZT sol-gel solution was transferred onto the entire surface of the chip by manually pressing the stamp, and the film was pyrolyzed at 350  $^\circ\text{C}$  for 300 s and subsequently crystallized at 650  $^\circ\text{C}$  for 60 s. This printing process was repeated seven times to achieve a final film thickness of  $281 \text{ nm} \pm 7 \text{ nm}$  (figure 1(4)). The resulting films showed microstructures characteristic of the perovskite phase, with a small amount of pyrochlore observed at triple points. Printed 30/70 PZT features exhibited a relative permittivity of 500 and a loss tangent of 0.9%. The hysteresis loops were well formed, without pinching of the loops. The patterned features showed remanent polarizations of  $27 \mu\text{C cm}^{-2}$ , and coercive fields of  $110 \text{ kV cm}^{-1}$ . Since the cantilever and bottom electrode was defined before the PZT printing step, as shown in figure 1(3), there was no need for precise alignment during stamping to achieve PZT film patterning on the cantilever.

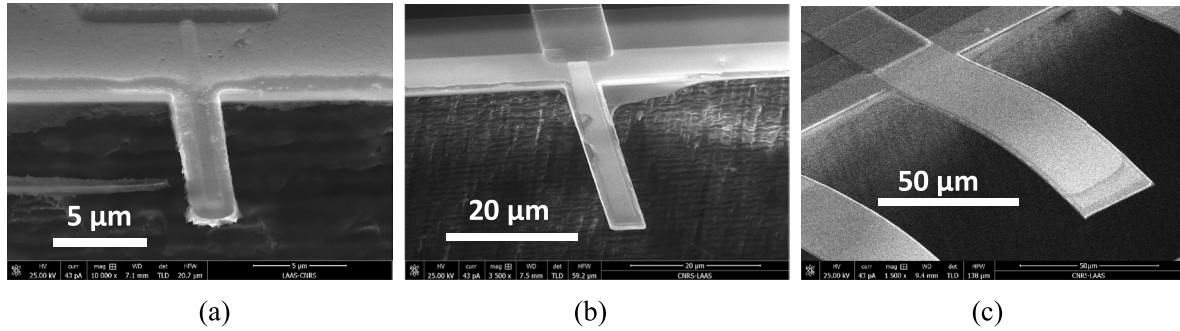
In order to access the bottom electrode, the PZT film was patterned by wet etching in buffered hydrofluoric acid (BOE) after a photolithography step using SPR1813 photoresist (figure 1(5)). Then, the Ti/Pt bottom electrode was patterned by reactive ion etching with a 6  $\mu\text{m}$  thick photoresist mask (figure 1(6)) and a 30 nm thick Pt top electrode was patterned by lift off (figure 1(7)). For this step, ZEP520A electron beam resist was patterned via electron beam lithography (EBPG 5200, Vistec) using a beam current of 40 nA, a dose of  $365 \mu\text{C cm}^{-2}$ , an aperture size of 400  $\mu\text{m}$ , and a beam step size of 25 nm. After development of the photoresist, the Pt was sputtered and lifted off.

The next step was dedicated to patterning the ground plane, in order to allow the top Si layer of the SOI wafer to be electrically grounded (not shown in figure 1). This process consisted first of etching the  $\text{HfO}_2$  and  $\text{SiO}_2$  films to expose the top Si layer everywhere on the chip surface, except at the electrode and cantilever locations. Then Ti/Al (100 nm/700 nm) was deposited on the exposed Si surface. This metallization of Ti/Al was done at the same time as the metallization of the electrical circuits in the following step (figure 1(9)). As discussed in section 3.1, this step eliminated the parasitic capacitance between the electrodes and the device Si layer.

In order to prevent electrical shorts between the bottom electrode and the Ti/Al electrode deposited in the following process, a 100 nm thick  $\text{Si}_3\text{N}_4$  insulating film was patterned by lift-off using a bi-layer 300 nm thick LOR3A and 1  $\mu\text{m}$  thick ECI photoresist (figure 1(8)). The LOR3A layer was used to facilitate the lift-off process due to the re-entrant profile. The  $\text{Si}_3\text{N}_4$  insulating film was deposited by inductively-coupled plasma chemical vapor deposition (ICPECVD) in order to ensure a uniform and conformal deposition over the step



**Figure 1.** Fabrication process of free-standing silicon cantilevers with microcontact printed PZT films. (0) SOI wafer, (1) passivation:  $\text{SiO}_2$  (100 nm) +  $\text{HfO}_2$  (60 nm), (2) bottom electrode deposition:  $\text{TiO}_2/\text{Pt}$  (30/100 nm), (3) cantilever profile definition, (4) microcontact printing of PZT, (5) PZT patterning, (6) patterning of bottom electrode, (7) patterning of top electrode, (8) insulation:  $\text{Si}_3\text{N}_4$  (100 nm), (9) electrical circuits metallization:  $\text{Ti}/\text{Al}$  (100/700 nm), and (10) structures release.



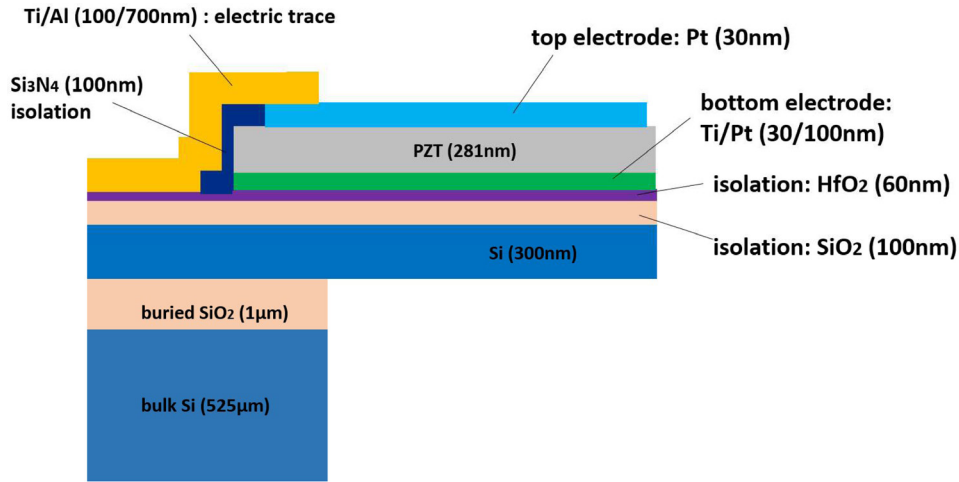
**Figure 2.** SEM images of cantilevers with microcontact printed PZT films. (a) Short (10  $\mu\text{m}$  long), (b) medium size (35  $\mu\text{m}$  long) and (c) long (150  $\mu\text{m}$  long) PZT coated cantilevers.

formed by the bottom electrode and PZT layer. Electrical connections were made by lift-off patterning of 100 nm/700 nm  $\text{Ti}/\text{Al}$  using 2.6  $\mu\text{m}$  thick nLOF photoresist (figure 1(9)). Finally, backside etching for cantilever release was performed by deep reactive ion etching of the handle Si wafer using a 40  $\mu\text{m}$  thick AZ40XT photoresist mask, followed by etching of the buried  $\text{SiO}_2$  layer (figure 1(10)). Scanning electron microscopy photographs of the fabricated PZT covered cantilevers are shown in figure 2.

Each cantilever is a multilayer composed of 300 nm thick Si, 100 nm thick  $\text{SiO}_2$ , 60 nm thick  $\text{HfO}_2$ , 30 nm/100 nm thick  $\text{Ti}/\text{Pt}$  layers as the bottom electrode, 281 nm thick microcontact

printed PZT layer, and 30 nm thick Pt top electrode, as shown in figure 3. An unreleased cantilever with exactly the same structure was integrated onto the same chip, serving as a reference to compensate the static capacitance of the piezoelectric stack during electrical characterization, as described in section 3.1.

Three different types of cantilevers (depicted in table 1) were designed in order to study possible dimensional effects upon PZT film properties: the short cantilevers are 10  $\mu\text{m}$  long and 2  $\mu\text{m}$  wide. The medium size cantilevers are 35  $\mu\text{m}$  long, 5  $\mu\text{m}$  wide. Lastly, the long cantilevers are 150  $\mu\text{m}$  in length and 30  $\mu\text{m}$  in width.



**Figure 3.** Scheme of the integrated piezoelectric stack.

**Table 1.** Dimensions of the fabricated cantilevers.

	Short cantilever	Medium cantilever	Long cantilever
Length	10 $\mu\text{m}$	35 $\mu\text{m}$	150 $\mu\text{m}$
Width (except top Pt layer)	2 $\mu\text{m}$	5 $\mu\text{m}$	30 $\mu\text{m}$
Width (top Pt layer)	1 $\mu\text{m}$	3 $\mu\text{m}$	26 $\mu\text{m}$

### 3. Measurement of the cantilever resonance frequency using the PZT piezoelectric response

#### 3.1. Electrical set-up

A schematic of the apparatus used for resonance frequency measurements [16, 20] is shown in figure 4. To operate the device, a sinusoidal voltage  $V_1$  was applied between the top and bottom electrodes on the piezoelectric layer, leading to the motion of free-standing cantilevers due to the converse piezoelectric effect. An opposite voltage  $-V_2$  was also applied to an unreleased structure with the same dimensions which served as a reference to reduce the effect of the static capacitance of the PZT layer. The charges generated by the two structures were collected by the common bottom electrode and were amplified through a charge amplifier (1 V/pC gain). The signal was then injected into a demodulator to extract both amplitude and phase.

The top Si layer was grounded to eliminate the charges generated by the parasitic capacitances  $C_1$  and  $C_2$ , and the charges from  $C_s$  were compensated by the reference; where  $C_1$  is the parasitic capacitance between the top electrode trace line and the top Si layer of the SOI,  $C_2$  is the parasitic capacitance between the bottom electrode line and the top Si layer of the SOI,  $C_s$  is the static capacitance of the PZT (dielectric) layer sandwiched between the top and bottom electrodes, and  $C_{\text{mot}}$  is the motional capacitance corresponding to the charges generated by the PZT layer during the resonator motion due to the direct piezoelectric effect.

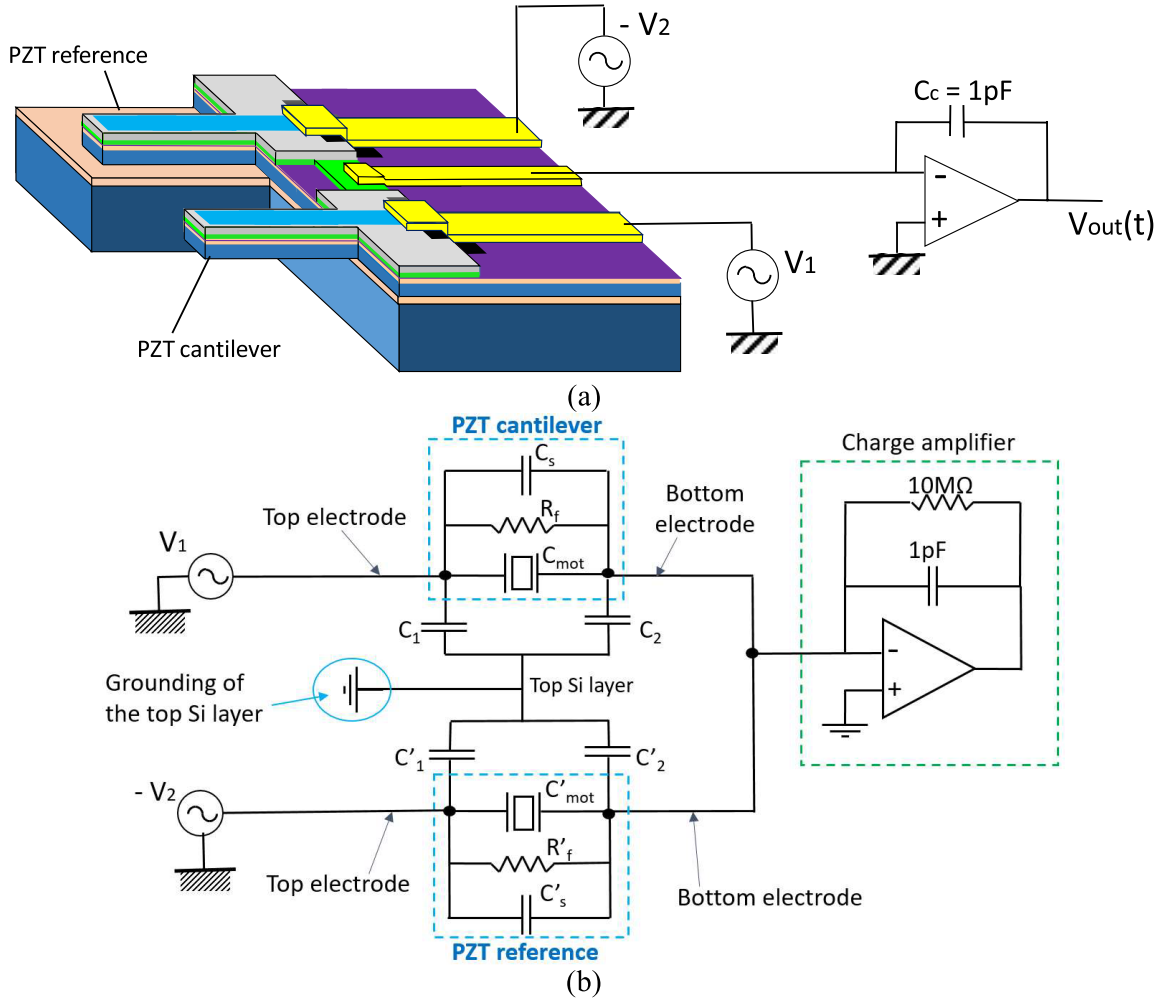
#### 3.2. Detection of resonance frequency by piezoelectrical response and effect of poling on PZT films

Using this electrical set up, the resonance frequencies of the medium size and long PZT cantilevers were detected through

their piezoelectric responses. At first, the measurements were done without poling treatment of the PZT films. In order to improve the PZT layer properties and obtain a larger amount of charges upon cantilever deflection, the PZT was poled [20, 22–29] by applying 3 V between the top and bottom electrodes (i.e.  $107 \text{ kV cm}^{-1}$  across the 281 nm thick PZT layer) at a temperature of 150 °C. A commercial Cascade Summit 12000 probe station allowed the Si chips to be heated while placing needle probes on the electrodes in order to pole the PZT and a Keithley 4200 was used to apply the DC voltage between the top and bottom electrodes.

The frequency spectra of the first mode resulting from the charges generated by the PZT layer with variation of poling time are shown in figure 5. In the case of the long cantilevers (figure 5(a)), even before poling, the resonance frequency could be detected using an actuation voltage ( $V_1$ ) of 100 mV as shown in figure 5(a) ‘Before poling’. After 15 min of poling, the amplitude of the resonance peak increased by 33%. By poling for 120 min more (for a total of 135 min), the charges generated at the resonance peak increased further to 230 fC (from an unpoled value of 120 fC). The detected resonance frequency of the first mode was 18.3 kHz and quality factor in air was 67. The second and third modes were also detected: 102.3 kHz with a Q factor of 182 and 291.6 kHz with a Q factor of 266, respectively.

In the case of the medium size cantilevers (figure 5(b)), the effect of poling was more remarkable. Before poling, the charge detected at resonance was only 1.4 fC for an actuation voltage of 700 mV. However, after 15 min of poling, the charges generated at resonance were found to dramatically increase up to 10 fC for an actuation voltage of 100 mV. By applying the poling protocol for 120 min more (for a total of 135 min), the generated charges further increased to 29.6 fC. The detected resonance frequency of the first mode was 473 kHz and the quality factor in air was 223. The second mode was 2.36 MHz with Q factor 388. For both long and medium size cantilevers, extending the poling treatment to a total of 255 min (120 min more) did not lead to any observable enhancement of the generated charges level (data not shown). Thus, 135 min of poling time maximized the PZT properties.



**Figure 4.** Schematic sketch of electrical detection. (a) Electrical connections of the device, and (b) details of the measurement electronics including the electrical model of the cantilevers.

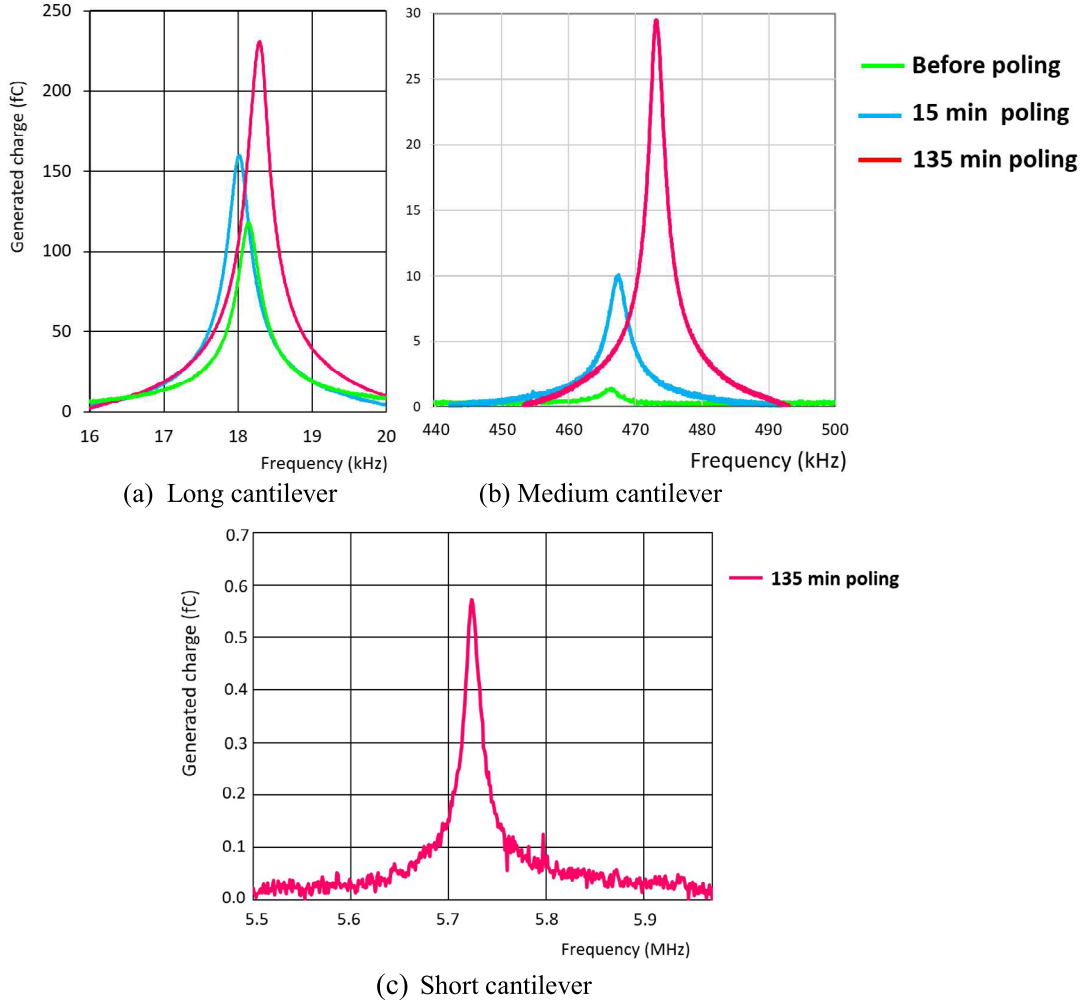
As for the short cantilever ( $10 \mu\text{m}$  in length,  $2 \mu\text{m}$  in width), figure 5(c) shows that before poling, the resonance frequency could not be detected. However, after performing a 135 min poling step, the resonance frequency was detectable. The amount of charges generated at resonance was  $0.56 \text{ fC}$  for an actuation voltage of  $20 \text{ mV}$ . The measured resonance frequency was  $5.72 \text{ MHz}$  with a quality factor in air of 381. Hence, the capability of simultaneous actuation and detection of the cantilevers using microcontact printed PZT layers was validated even with the short cantilever.

For the medium and short cantilevers, the measured first mode resonance frequencies of  $473 \text{ kHz}$  and  $5.72 \text{ MHz}$ , respectively, are about 8% smaller than the simulated value of  $508.0 \text{ kHz}$  and  $6.215 \text{ MHz}$ , obtained with the analytical model of a laminated beam described in section 4.1 [30, 31]. As will be discussed in sections 4.1 and 4.5, these slight differences may be attributed to non-ideal clamping of the cantilevers.

In the case of the long cantilever, the measured fundamental mode was  $18.2 \text{ kHz}$  while the simulated one was  $27.75 \text{ kHz}$ . Hence, the difference between experimental and theoretical resonance frequency values reaches 52% in the case of long cantilevers. This large discrepancy is believed to be a consequence of a decrease in the cantilever's thickness due to

overetching during fabrication. According to the analytical model which will be mentioned in section 4.1, the Si layer thickness of the long cantilever may be decreased to  $90 \text{ nm}$ . It is because of non-uniformity in etching speed of the deep reactive ion etching of the handle Si wafer during the release of the cantilever structures (figure 1(10)). The etching speed is slower on the edge of the etching patterns. The medium and the short cantilevers are situated on the edge of the etching patterns. Hence, while the etching for releasing long cantilever is about to be finished, the medium and the short cantilevers are not yet released. To complete the release process of all cantilevers, the long cantilevers may suffer from overetching.

As can be seen in figure 5, the measured resonance frequencies slightly increase after the 135 min poling treatment, for the long cantilever from  $18.2 \text{ kHz}$  (before poling) to  $18.3 \text{ kHz}$  (after 135 min poling) and for the medium cantilever from  $466.6 \text{ kHz}$  (before poling) to  $473.2 \text{ kHz}$  (after 135 min poling). This results can be attributed to the remanent strain induced by the alignment of the PZT dipoles towards the direction of the applied field during poling [24, 25]; the resulting in-plane contraction [26, 27] should have produced a curvature change of the cantilevers. For these poling conditions, aging [28, 29] was limited, as demonstrated by the stability of the resonance



**Figure 5.** Resonance spectra with variation of poling time. (a) 150  $\mu\text{m}$  long cantilever actuated with  $V_1 = 100$  mV, (b) 35  $\mu\text{m}$  long (medium size) cantilever actuated with  $V_1 = 700$  mV before poling and 100 mV after poling, and (c) 10  $\mu\text{m}$  long (short size) cantilever actuated with  $V_1 = 20$  mV after poling.

peak amplitudes during measurements spanning a period of two months.

#### 4. Estimation of the piezoelectric coefficient $d_{31}$

Estimation of the piezoelectric coefficient  $d_{31}$  was done by modeling the PZT cantilever as a laminated beam and by comparing the result of the model to two sets of experimental results at a particular resonance. First, the motional capacitance  $C_{\text{mot}}$  was obtained from impedance data at resonance, from which the piezoelectric response was extracted. Secondly, the displacement of the tip of the cantilever as a function of the voltage applied to the piezoelectric layer was detected by a laser vibrometer. This was modeled using equivalent single layer beam theory for the laminated beam, with all details given in the [appendix](#). The following section presents a comparison of the analytical model and finite element model (FEM, ABAQUS) used for model validation and then the method used to determine the  $d_{31}$  coefficient.

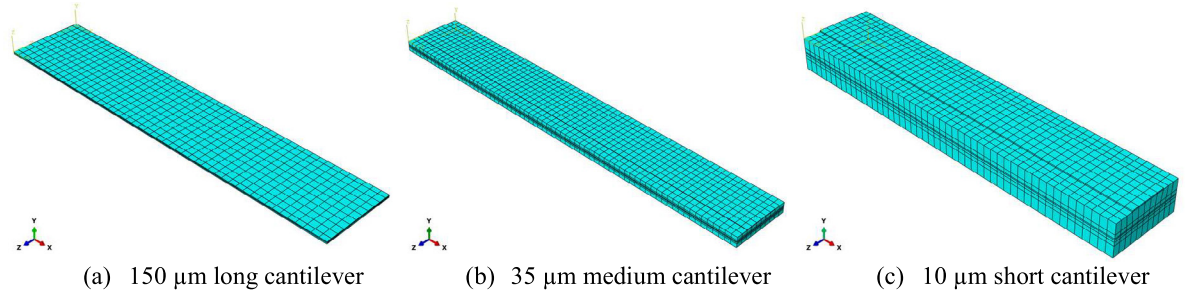
**Table 2.** Properties of layers of the cantilever [32, 33].

	Thick-ness (nm)	Mass densi-ty ( $\text{kg m}^{-3}$ )	Young's mod-ulus (GPa)
Pt (top)	30	21 450	145
PZT	281	7 800	105
Pt (bottom)	100	21 450	145
Ti	30	4 510	110
HfO <sub>2</sub>	60	9 700	57
SiO <sub>2</sub>	100	2 150	70
Si	300	2 500	169

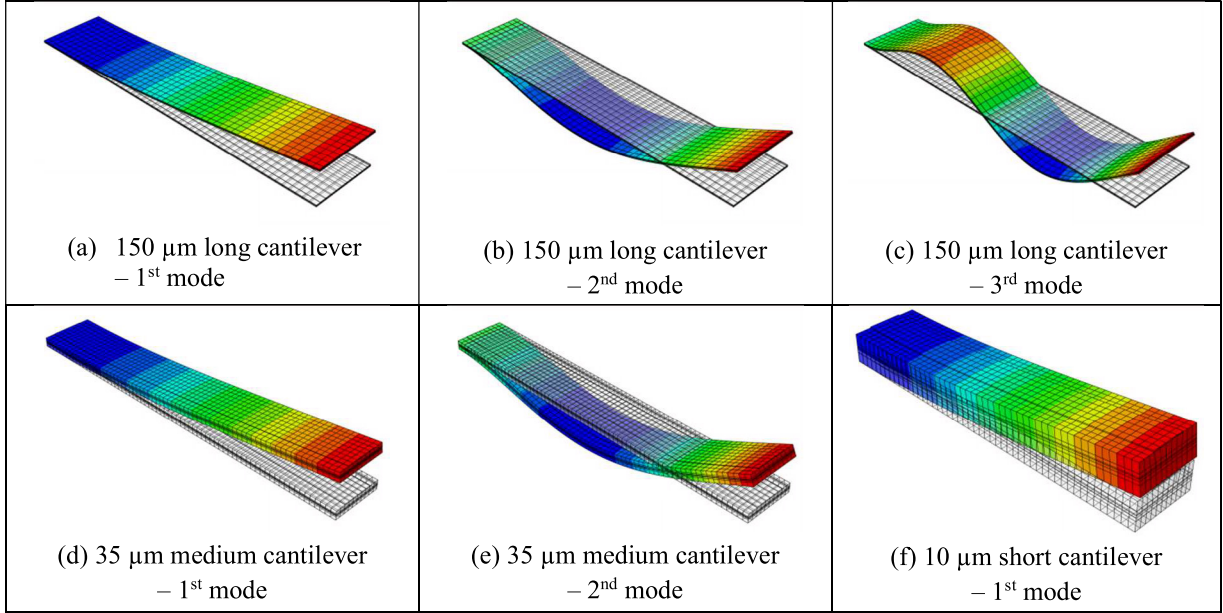
##### 4.1. Validation of the beam model with finite element computations—modal analysis

As explained in the appendix, the  $k$ th natural frequency is given by the equivalent single layer beam model of the cantilever [30]:

$$f_k = \frac{\beta_k^2}{2\pi L} \sqrt{\frac{\hat{D}}{m}} \quad (1)$$



**Figure 6.** Meshes used in the FE computations. (a) The long cantilever, (b) the medium cantilever and (c) the short cantilever.



**Figure 7.** Mode shapes of some bending modes of the cantilevers obtained by finite element simulations with ABAQUS. (a) 1st mode of the long cantilever, (b) 2nd mode of the long cantilever, (c) 3rd mode of the long cantilever, (d) 1st mode of the medium cantilever, (e) 2nd mode of the medium cantilever, and (f) 1st mode of the short cantilever.

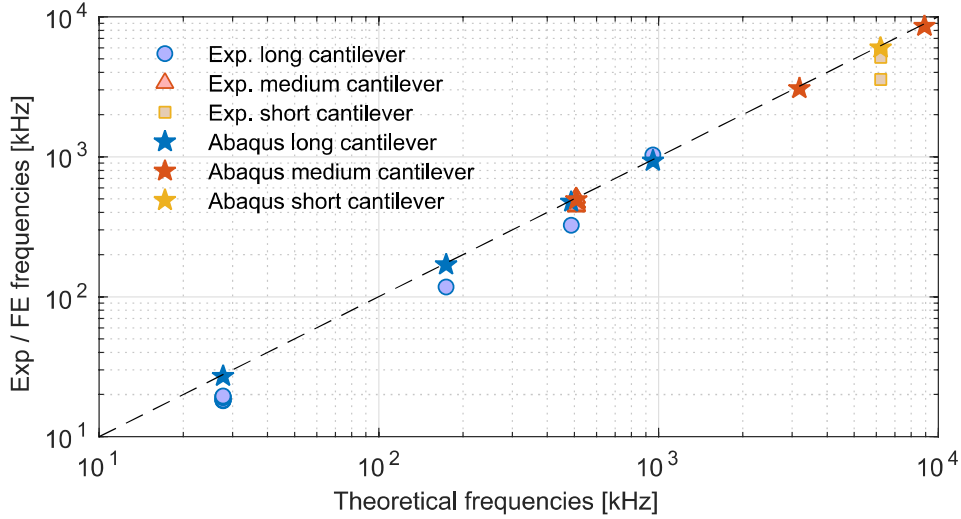
with  $\beta_1 = 1.875$ ,  $\beta_2 = 4.694$ , etc and where  $\hat{D}$  is the bending stiffness and  $m$  is the mass per unit length of the beam. These results were compared with a 3D finite element model of the structures, built in the commercial code ABAQUS. The three cantilevers defined in tables 1 and 2 were considered [32, 33]. The finite-element meshes are shown in figure 6. Each physical layer of the cantilevers is meshed with one layer of hexahedral finite elements with 20 nodes and quadratic shape functions (C3D20 finite elements), that include electric degrees of freedom for the PZT layer (C3D20E finite elements). The convergence was checked with refined meshes; those results are less than 0.1% different than the meshes of figure 6. Figure 7 shows the mode shapes of some bending modes of the cantilevers obtained by finite element simulations with ABAQUS.

Figure 8 and table 3 show the natural frequencies of the beam obtained by the single layer model as a function of the ones obtained by the finite element computations. A difference of about 3% is observed between the two approaches. Considering the aspect ratios of the cantilevers (close to a thin plate for the 150  $\mu\text{m}$  long cantilevers and close to a thick beam with a small aspect ratio for the 10  $\mu\text{m}$  short cantilevers), as

well as their complex lamination (seven layers), this error can be considered very small, which validates the equivalent single layer beam model. We also compared the natural frequencies of the cantilevers for different electrical boundary conditions (without piezoelectric effects, PZT layer in short circuit and PZT layer in open circuit) with  $d_{31} = 10 \text{ pm V}^{-1}$  for the piezoelectric coefficient. Differences less than 0.1% were noticed, which is consistent with the small piezoelectric coupling factor (less than 1%) associated with this  $d_{31}$  value (see [34] for details about the piezoelectric effect on the natural frequencies in short and open circuit and their relation to the electromechanical coupling factor).

The experimental frequencies of the cantilevers of section 3.2 are also shown in figure 8. A line of slope 1 is provided, showing good agreement between the experimental and theoretical values of the resonance frequencies. It is notable that the experimental natural frequencies are smaller than those predicted by the theory. This can probably be explained by the non-ideal clamping with a smaller stiffness in experiments than in theory, as will be shown in figure 14, as well as some unavoidable uncertainties on the material constants values of the six materials used in the complex lamination of the beams.





**Figure 8.** Experimental (Exp.) resonance frequencies and finite element (ABAQUS) natural frequencies as a function of theoretical (equivalent single layer beam theory) natural frequencies of the cantilevers. The dashed line has a slope of one.

**Table 3.** Comparison of natural frequencies from the equivalent single layer beam theory and the reference 3D finite element computation.

	150 $\mu\text{m}$ long cantilever			35 $\mu\text{m}$ medium cantilever		10 $\mu\text{m}$ short cantilever
	Mode 1	Mode 2	Mode 3	Mode 1	Mode 2	Mode 1
Single layer beam theory [kHz]	27.75	173.95	487.06	508.03	3184.1	6214.5
Finite elements [kHz]	27.09	169.54	475.44	492.63	3074.8	5985.90
Error [%]	2.39	2.53	2.39	3.0	3.4	3.68

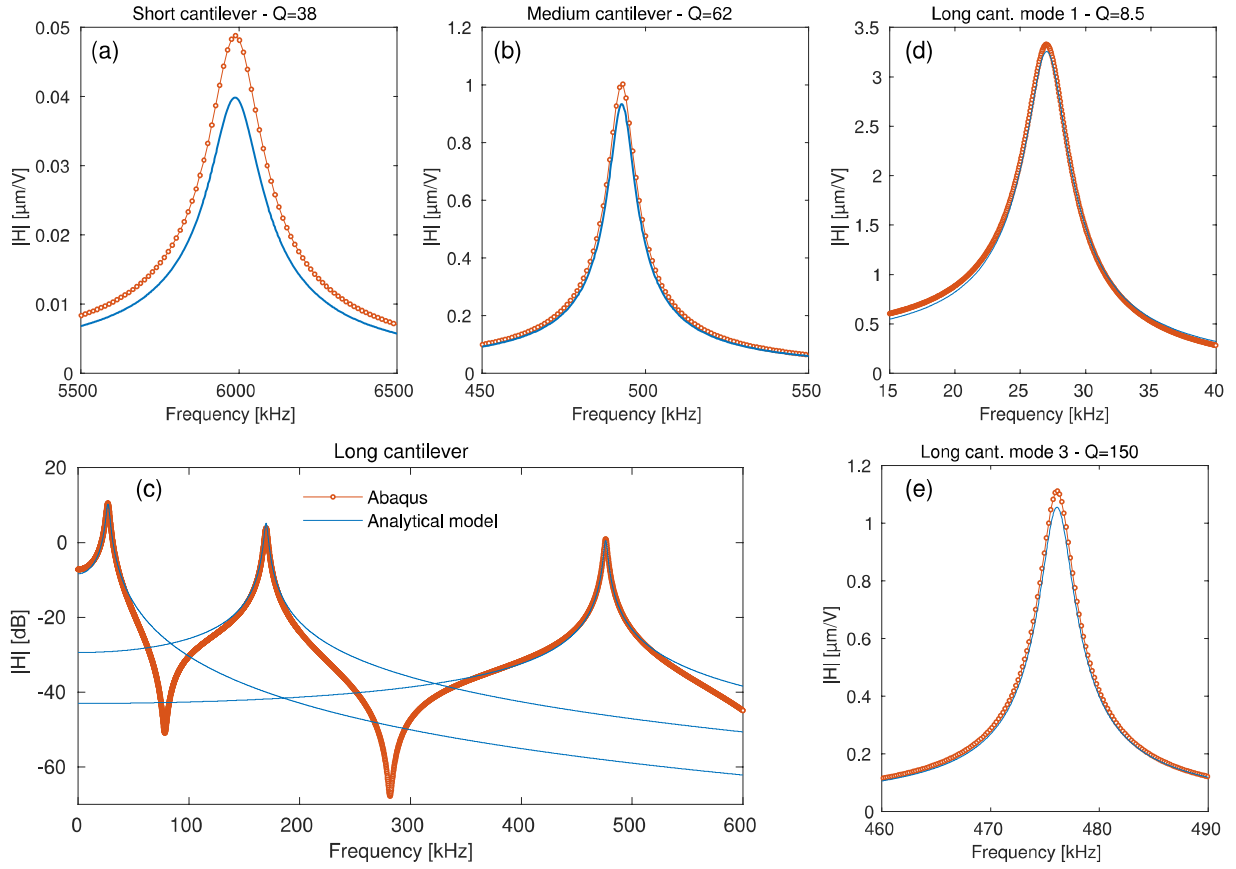
In the case of the long cantilever, the reduction in experimental natural frequency was caused by overetching during fabrication, as discussed in section 3.2.

#### 4.2. Validation of the beam model with finite element computations—frequency response functions with piezoelectric effect.

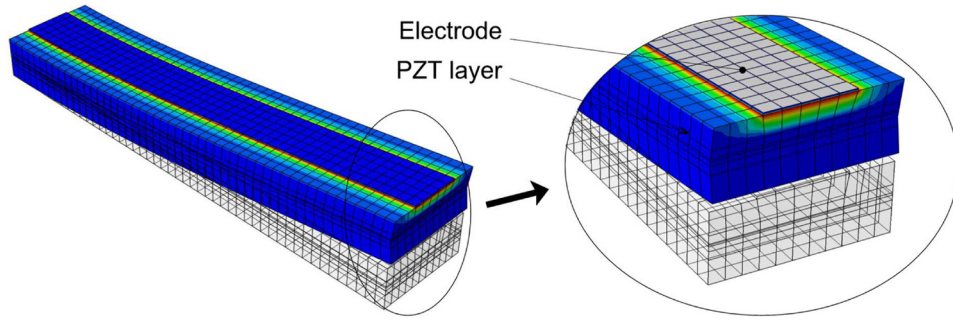
The mechanical frequency response (FRF) of the cantilevers determined by the equivalent single layer theory and by realistic finite-element computations was compared. A sinusoidal voltage of frequency  $\Omega$  was applied to the PZT layer  $V(t) = V_0 \cos \Omega t$ . The resulting tip displacement  $w_t(t) = w_{t0} \cos(\Omega t + \varphi)$  of the cantilevers by both models was then calculated and compared. The amplitude of the frequency response is simply  $H(\Omega) = w_t/V_0$ . For the finite-element computations, the frequency response is obtained at each frequency  $\Omega$  with an inversion of the dynamical stiffness matrix (direct steady-state dynamics in ABAQUS). A mass-proportional damping is used, for which the damping matrix is  $C = aM$ , where  $M$  is the mass matrix.  $a$  was chosen so that quality factors between 10 to 200 were obtained for the modes of interest for the three cantilevers (short cantilever:  $a = 10^6 \text{ s}^{-1}$ , medium cantilever:  $a = 50 \cdot 10^3 \text{ s}^{-1}$ , long cantilever:  $a = 20 \cdot 10^3 \text{ s}^{-1}$ ). For the  $k$ th angular natural frequency,  $\omega_k$ , computed by the finite element model,  $Q_k = \omega_k/\alpha$ . For the analytical model, equations (A.11) and (A.14) in the

appendix are used. All the other parameters ( $\chi_k$ ,  $m$ ,  $L$ ) were computed with the geometrical and material characteristics of the cantilevers (tables 1 and 2). Moreover, the width  $b_p$  of the piezoelectric layer used in equation (A.4) in the appendix to compute the piezoelectric constants  $\Theta$  and  $\Xi$  was set equal to the top electrode width (see table 1), since most of the electric field lines created in the PZT layer encompass the volume just below the top electrode. Besides, in the analytical model, the electric field in the piezoelectric layer is independent of  $y$ .

Figure 9 shows  $H(\Omega)$  for the three cantilevers, computed by the single layer theory and the finite-element model. Very good agreement is obtained for the three cantilevers, with a slight underestimation of the frequency response by the analytical model. This effect is mainly observed in the case of the first mode of the short cantilever. This can be explained by the relatively large aspect ratio of this cantilever (the ratio between its length and the cross-sectional thickness is 11 for the short cantilever, see figure 10), for which the Euler–Bernoulli theory is at its limits. Moreover, as shown in figure 10, there are fringing electric field lines in the PZT layer that extend beyond the top electrode, which results in an increased active PZT volume with respect to that considered in the analytical model. Those effects are smaller for the medium and the long cantilever, with larger aspect ratios (38 and 166, respectively). Given the good agreement between measured and modeled response, the analytical model can be used for the  $d_{31}$  piezoelectric coefficient estimations.



**Figure 9.** Frequency response functions: tip displacement of the cantilevers for a unit voltage in the PZT layer as a function of driving frequency. Comparison between reference finite element computation results with ABAQUS (orange lines) and results from the equivalent single layer model (blue lines. Solid: 4 mode model; dashed: single mode model). (a) The short cantilever, (b) the medium cantilever, (c) the long cantilever (1st, 2nd and 3rd modes), (d) 1st mode of the long cantilever, and (e) 3rd mode of the long cantilever.



**Figure 10.** Deformed shape at the first resonance of the short cantilever with the electrical potential shown in color.

#### 4.3. Estimation of the $d_{31}$ coefficient

The  $d_{31}$  piezoelectric coefficient was estimated by measuring the motional capacitance  $C_{\text{mot}}$  of the cantilevers (the ratio between the number of piezoelectrically created electric charges and the input voltage) at a specific resonance. The piezoelectric response in the analytical model was then adjusted so that the modeled response fit the experimental data. This method has been used successfully in a previous work [18]. As shown in the appendix (equation (A.19)), the motional capacitance  $C_{\text{mot}}$  for the cantilevers can be written as:

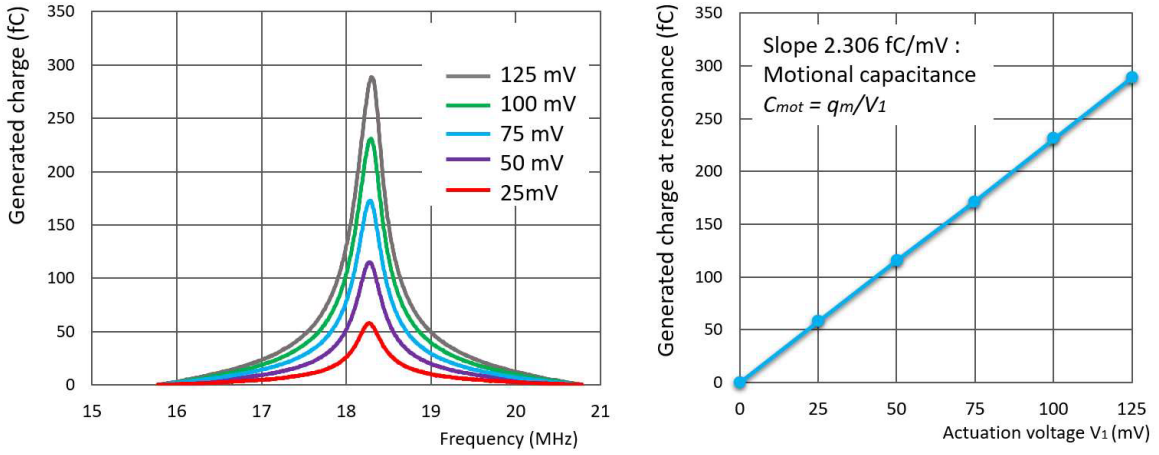
$$C_{\text{mot}} = \alpha d_{31}^2 \text{ with } \alpha = \frac{Q_k Y_p^2 \bar{\Theta}'^2 \Phi_k'^2(1)}{mL^3 \omega_k^2}. \quad (2)$$

The  $\alpha$  parameter ( $(\text{N m}^{-1})$ ) is a function of the  $k$ th eigenmode (quality factor  $Q_k$ , natural frequency  $\omega_k$  and mode shape slope at the tip  $\Phi_k'$ ), the Young's modulus of the PZT layer  $Y_p$ , the length  $L$  of the cantilever and the piezoelectric constant  $\bar{\Theta}'$  proportional to the PZT layer mean height with respect to the neutral line of the cantilever.

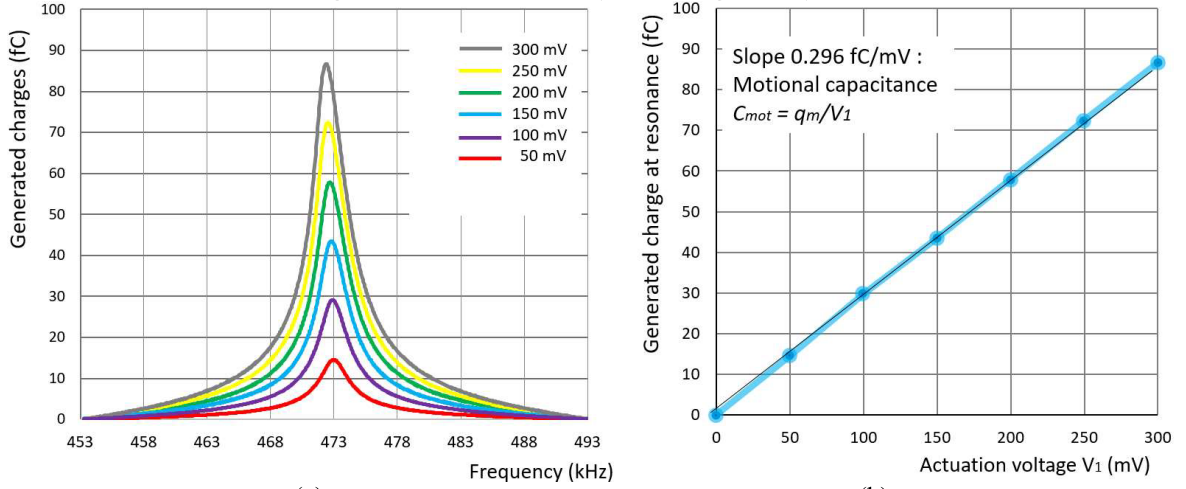
For each cantilever,  $d_{31}$  is estimated by:

$$d_{31} = \sqrt{\frac{C_{\text{mot}}}{\alpha}} \quad (3)$$

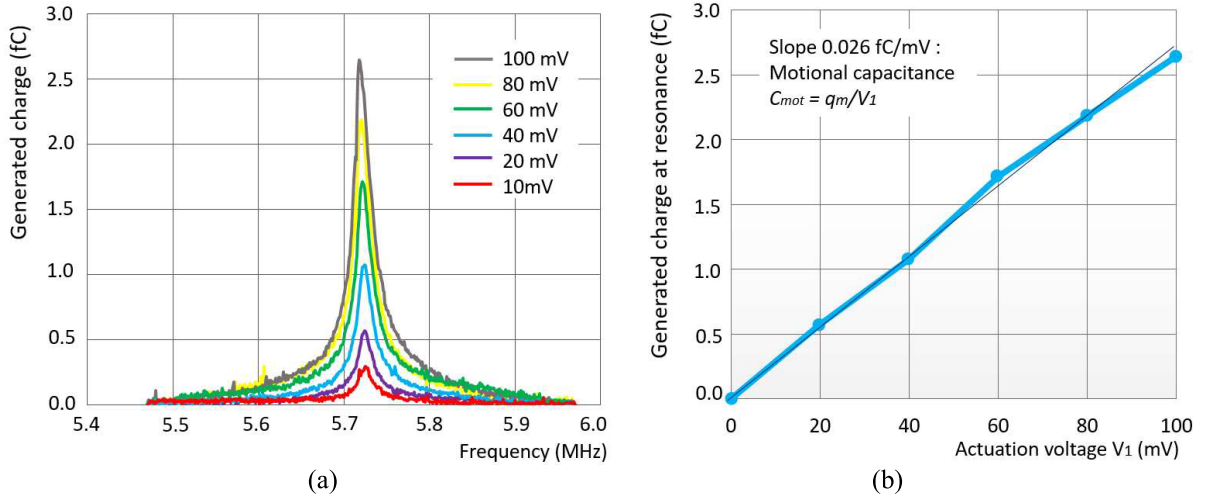
where  $C_{\text{mot}}$  is obtained by recording the resonance spectra as a function of actuation voltage and  $\alpha$  is computed using the values of tables 1 and 2 for  $Y_p$ ,  $L$  and  $\bar{\Theta}'$ , the theoretical



(a) (b)  
(1) Long PZT cantilever: 150  $\mu\text{m}$  in length, 30  $\mu\text{m}$  in width



(a) (b)  
(2) Medium PZT cantilever: 35  $\mu\text{m}$  in length, 5  $\mu\text{m}$  in width



(a) (b)  
(3) Short PZT cantilever: 10  $\mu\text{m}$  in length, 2  $\mu\text{m}$  in width

**Figure 11.** (a) Piezoelectric responses of the PZT cantilevers as a function of actuation voltage after a 135 min poling process, (b) slope of the generated charge at the resonance peak as a function of actuation voltage. (1) The long cantilever, (2) the medium cantilever and (3) the short cantilever.

mode shapes for  $\Phi'_k$  (equation (A.10) in the appendix) and the experimental values of  $Q_k$  and  $\omega_k$ .

Figure 11(a) shows the 1st mode resonance response of the motional capacitance (for cantilevers after 135 min poling

treatment). A plot of the generated charges as a function of actuation voltage at resonance shows excellent linear behavior (figure 11(b)), permitting determination of the experimental values of  $C_{mot}$ . In the case of the long PZT cantilever, the

**Table 4.** Evolution of  $d_{31}$  ( $\text{pm V}^{-1}$ ) values, resonance frequencies and Q factor as a function of poling time.

	Poling time	Before poling	15min	135min	255min
Long cantilever	$d_{31}$ ( $\text{pm V}^{-1}$ )	5.1	6.0	7.2	7.1
	Resonance (kHz)	18.2	18.0	18.3	18.3
	Q factor (in air)	66	65	67	67
Medium cantilever	$d_{31}$ ( $\text{pm V}^{-1}$ )	1.2	9.0	14.2	13.9
	Resonance (kHz)	466.6	467.4	473.2	472.9
	Q factor (in air)	208	185	223	228
Short cantilever	$d_{31}$ ( $\text{pm V}^{-1}$ )	Undetectable	Not estimated	11.5	10.9
	Resonance (MHz)		Not measured	5.72	5.71
	Q factor (in air)		Not estimated	381	382

applied voltage  $V_0$  varied from 25 mV to 125 mV (figure 11(1)) and in the case of the medium PZT cantilever, it varied from 50 mV to 300 mV (figure 11(2)). The average quality factor and experimental values of  $C_{\text{mot}}$  were estimated to be 67 and 223, and  $2.306 \text{ fC mV}^{-1}$  and  $0.296 \text{ fC mV}^{-1}$ , respectively for the long and medium cantilever. For the short PZT cantilevers, with applied voltage  $V_0$  ranging from 10 mV to 100 mV (figure 11(3)), the average quality factor and the experimental values of  $C_{\text{mot}}$  were estimated to be 381 and  $0.026 \text{ fC mV}^{-1}$ .

#### 4.4. Estimated values of the $d_{31}$ coefficient and its evolutions with poling time

The piezoelectric coefficient  $d_{31}$  was calculated using the motional capacitance  $C_{\text{mot}}$  and quality factors estimated in the previous section. Piezoelectric coefficients  $d_{31}$  of  $-6.9 \pm 0.1 \text{ pm V}^{-1}$ ,  $-12.0 \pm 2.0 \text{ pm V}^{-1}$  and  $-11.0 \pm 2.4 \text{ pm V}^{-1}$  were calculated respectively for the long, medium size and short cantilevers for the first mode. These calculated values of  $d_{31}$  were smaller than those previously reported [19, 21], where values of  $d_{31}$  were estimated to be around  $50 \text{ pm V}^{-1}$  for PZT films with a thickness in the 100–200 nm range. These lower values are due to the use of a PZT composition off of the morphotropic phase boundary, as well as potential degradation of PZT layer induced by the presence of hydrogen [35] most probably during ICPECVD process for deposition of  $\text{Si}_3\text{N}_4$  film (figure 1(8)), even though annealing of  $400 \text{ }^\circ\text{C}$  30 min in  $\text{N}_2$  atmosphere was conducted to eliminate hydrogen molecules from the PZT layer.

The  $d_{31}$  values were calculated for each poling time for several cantilevers of each size. The evolution of  $d_{31}$  values as a function of poling time are shown in figure 12 and table 4. In the case of the medium size cantilever, the generated charges at resonance before poling treatment were very low ( $1.4 \text{ fC}$  with  $700 \text{ mV}$  actuation voltage), leading to  $1.2 \text{ pm V}^{-1}$  for the  $d_{31}$  coefficient which is not unexpected for an unpoled piezoelectric. However, after 135 min of poling, the  $d_{31}$  value became comparable to that of the PZT film integrated into the long cantilever. As for the short cantilever, the  $d_{31}$  value was also comparable to that of the long cantilever PZT film after the poling process. The  $d_{31}$  values did not show any significant increase when the poling time exceeded 135 min. The small effective  $d_{31}$  values of the medium and small cantilevers before poling may be attributed to a number of factors,

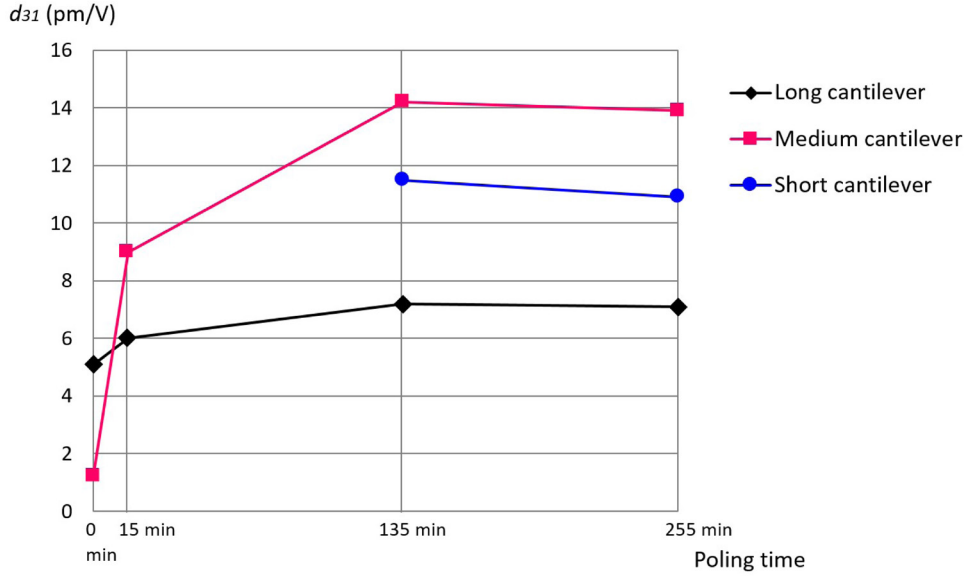
including changes in the defect chemistry of the films, imperfect boundary conditions for the mechanical devices, the size of the top electrode relative to the device dimensions, etc. Hence poling times as long as 135 min were required to saturate the polarization, while, for the long cantilever, a poling time of 15 min was enough.

It should be noted that saturated  $d_{31}$  values in the long cantilever is smaller than those of medium and small cantilever. This is attributed to fringing of the electric field through the PZT film. As shown in table 1, the width of the top electrodes is smaller than that of the other layers. In the analytical calculation, the effective electric field through the PZT film is assumed to be confined to the top electrode dimension. However, in reality, the electric field through the PZT fringes beyond the bounds of the top electrode because the bottom electrode width is larger than the top electrode. This effect can be seen in the FE modelling shown in figure 10 in section 4.2. This fringing field through the PZT film is more remarkable for the short and medium cantilever, because the relative width differences between top electrode and PZT film are larger.

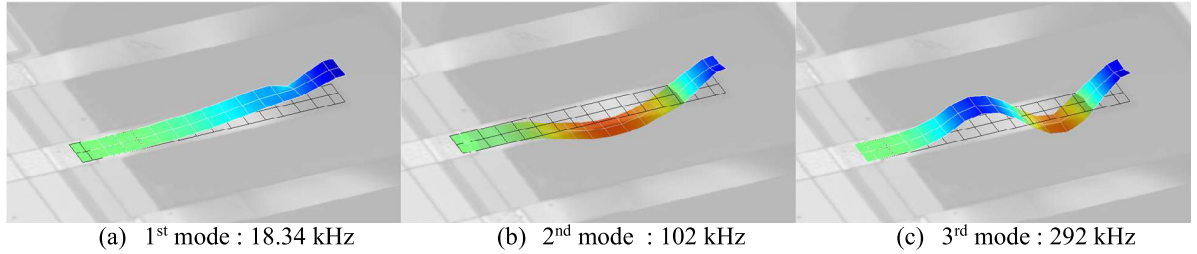
Table 4 also indicates the changes in resonance frequencies,  $d_{31}$  values and quality factors as a function of poling time for long, medium size and short cantilevers. As mentioned in section 3.2, poling treatment might lead to either changes in the mechanical characteristics of the PZT films or additional beam curvature. In general, the resonance frequencies of the cantilevers decrease after the first 15 min of poling, but after further poling, the resonance frequencies tend to increase along with the  $d_{31}$  values.

#### 4.5. Validation with mechanical frequency response measurements

To validate the  $d_{31}$  estimation method, the tip deflection of the cantilevers was measured using a Polytec MSA-500 laser vibrometer. The cantilevers were excited with a voltage signal (a periodic chirp) applied to the PZT and the velocity of several points on the cantilevers were measured. Figure 13 illustrates the deformed shape of a  $150 \text{ }\mu\text{m}$  long cantilever at its first three resonances, showing excellent qualitative agreement with the theoretical mode shapes of a cantilever beam. Figure 14(a) gives the deformed shape of a  $35 \text{ }\mu\text{m}$  medium cantilever around its fundamental resonance. To provide more quantitative insight, a detailed view of the anchor with



**Figure 12.** Evolution of  $d_{31}$  ( $\text{pm V}^{-1}$ ) as a function of poling time ( $107 \text{ kV cm}^{-1}$  at  $150^\circ \text{C}$ ), for short, medium and long size cantilevers.



**Figure 13.** First three bending mode shapes of a  $150 \mu\text{m}$  long cantilever measured with the laser vibrometer. (a) 1st mode, (b) 2nd mode, and (c) 3rd mode.

magnified amplitude is also given in figure 14(b), showing that, as suspected in section 4.1, the clamping of the cantilever is not perfect. Figures 14(c) and (d) show that the ratio between the maximum amplitude to the amplitude at the theoretical clamping zone ( $x = 0$ ) is very small, of the order of 1%. Similar results for non-ideal clamping have been observed in [36].

The laser was then focused on the tip of a cantilever and the frequency response  $H_v(\Omega)$  was determined from the measured velocity signal (obtained by fast Fourier transforms and averaged over time) divided by the input voltage. The results are identical to those obtained with a network analyzer and homodyne detection. Figure 15 shows the tip frequency response of a medium cantilever (with its fundamental resonance around 500 kHz) and of a long cantilever (with its first three resonance peaks). The short cantilevers frequency response was not measured since the maximum detection frequency of the laser vibrometer was 2 MHz, greater than their fundamental frequency.

From the equivalent single layer theory described in the appendix, the displacement amplitude at the tip of the cantilever  $w_{t0}$ , at resonance, is:

$$H(\omega_k) \approx \frac{w_{t0}}{V_0} = \gamma d_{31} \text{ with } \gamma = \frac{Q_k Y_p \widehat{\Theta}' \Phi_k(1) \Phi_k'(1)}{mL^2 \omega_k^2}, \quad (4)$$

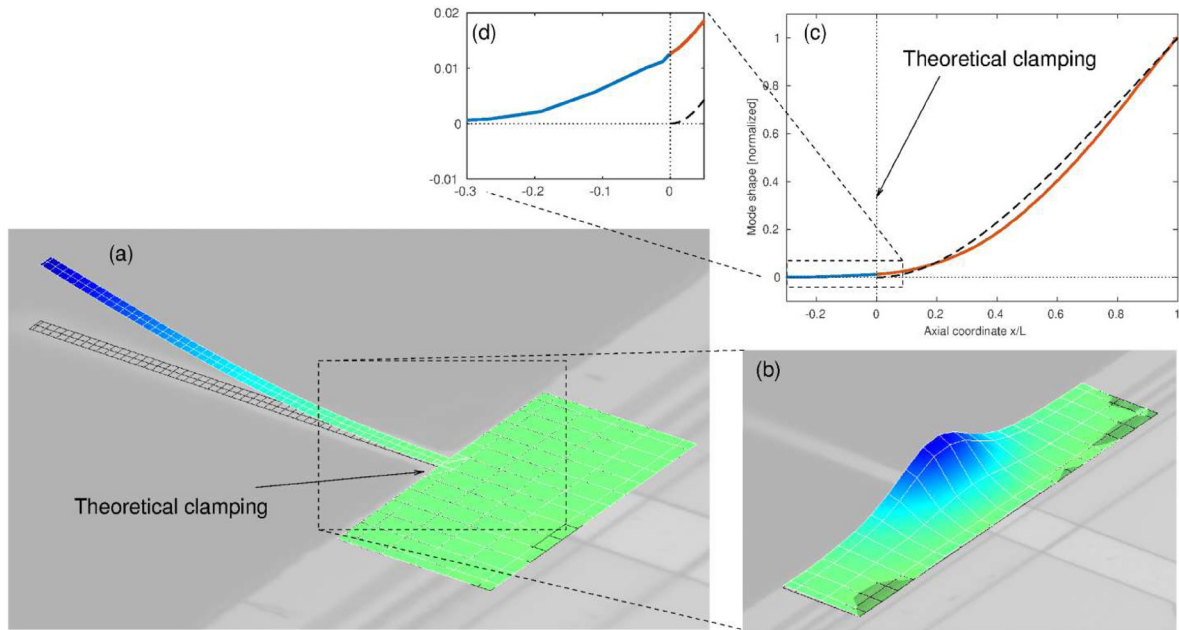
which allows the piezoelectric constant to be estimated as:

$$d_{31} = \frac{H(\omega_k)}{\gamma}. \quad (5)$$

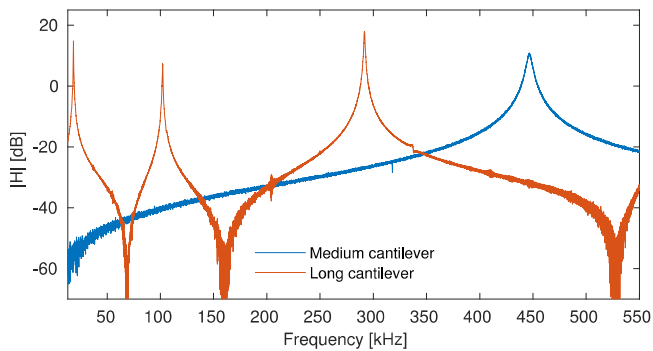
Around a given resonance, the natural frequency  $\omega_k$ , the Q-factor and the amplitude of  $H_v(\omega_k) = \omega_k H(\omega_k)$  ( $H_v$  is the velocity frequency response, whereas  $H$  is in displacement) were determined.

Table 5 shows the estimation of the  $d_{31}$  piezoelectric constant obtained from the motional capacitance and the laser vibrometer (mechanical response). The two methods are reasonably close. The measurements of this section were performed about 12 months after those of section 4.4. The obtained values are a little smaller, probably due to aging of the PZT layers.

The difference in  $d_{31}$  values between Mode 1 and Mode 3 may be attributed to non-uniformity in thickness along the cantilever, which is due to the non-uniformity in etching speed for releasing the cantilever structure in the fabrication process mentioned in section 3.2. This effect may cause non-ideal vibration shape of the 1st and 3rd mode resonance, which may cause variation in  $d_{31}$  values in different modes. It should be noted that, for the medium cantilever,  $d_{31}$  values of the motional capacitance and mechanical response estimation are substantially different,  $10.9 \text{ pm V}^{-1}$  for motional capacitance estimation and  $6.9 \text{ pm V}^{-1}$  for mechanical capacitance



**Figure 14.** First bending mode shape of a  $35\ \mu\text{m}$  long medium cantilever measured with the laser vibrometer at  $477.2\ \text{kHz}$ . (a) 3D view and (b) zoom on the anchor with magnified amplitude, (c) measured profile (solid line) taken from the 3D view, theoretical deformed shape (dashed line) and (d) zoom in at the anchor area.



**Figure 15.** Experimental frequency response functions: tip displacement of the cantilevers for a unit voltage in the PZT layer as a function of driving frequency, measured by the laser vibrometer.

**Table 5.** Estimated values of the  $d_{31}$  piezoelectric constant with the motional capacitance method and the mechanical frequency response method for two cantilevers of table 4.

	Long cantilever 1		Medium cantilever 2
	Mode 1	Mode 3	Mode 1
Natural frequency [kHz]	18.3	291.6	446.8
Quality factor	67	298	223
$d_{31}$ motional capacitance estimation [ $\text{pm V}^{-1}$ ]	7.2	8.3	10.9
$d_{31}$ mechanical response estimation [ $\text{pm V}^{-1}$ ]	8.7	7.8	6.9

estimation. This large discrepancy in  $d_{31}$  values is believed to be due to fringing fields through the PZT film as mentioned in sections 4.2 and 4.4, which is more remarkable in medium cantilever than the long cantilever. For the mechanical response estimation, this effect is very small.

In theory, the values of  $d_{31}$  should be the same for all cantilevers and that the discrepancies on the estimated values of  $d_{31}$  are large. However, two estimation methods have been proposed (motional capacitance by piezoelectric response and mechanical response by optical detection), each of them being the best that can be efficiently done, but relying on some uncertainties whose precise quantitative effect is difficult to estimate: fringing effect, exact geometries of the cantilevers close to the clamping, thicknesses variations etc. So, an average value of  $10\ \text{pm V}^{-1}$  seems to be a good order of magnitude of the obtained  $d_{31}$ .

## 5. Conclusions

Silicon based cantilevers integrating  $281\ \text{nm}$  thick microcontact printed  $\text{PbZr}_{0.3}\text{Ti}_{0.7}\text{O}_3$  films were fabricated. The resonance frequencies of the cantilevers were detected via the piezoelectric response of the integrated PZT films, thus validating the capability of simultaneous excitation and detection of the PZT cantilevers even at small sizes (e.g.  $10\ \mu\text{m}$ -long and  $2\ \mu\text{m}$ -wide cantilevers had a resonance frequency of  $5.7\ \text{MHz}$  and a Q factor of 381 in air). By analytical modelling of the PZT cantilevers and validations of the modelling by finite element simulation,  $d_{31}$  was estimated to be around  $10\ \text{pm V}^{-1}$ . Thin PZT films for realization of NEMS have been used for integrated actuation and detection on a geometrically complex elastic structure. This estimation of  $d_{31}$  piezoelectric coefficient was consistent with values obtained from the mechanical response measured by a laser vibrometer. Hence, microcontact printed PZT films with poling treatment offer promising transduction schemes for piezoelectric NEMS with integrated actuation and sensing capabilities.

## Acknowledgments

The French General Delegation for Armament and the French National Agency for Research (Grant ANR/PNANO 2008, project NEMSPIEZO ‘ANR-08-NANO-015’), and a National Security Science and Engineering Faculty Fellowship are gratefully acknowledged for financial support. Cédric Ayela and Isabelle Dufour from IMS Bordeaux as well as Dolores Manrique from LAAS Toulouse are acknowledged for technical support and open access to the laser vibrometer.

This work was supported by LAAS-CNRS technology platform, a member of Renatech network.

## Appendix. Single layer equivalent theory

As per the theory [30], a laminated beam composed of  $K \in \mathbb{N}$  elastic layers is considered, where one layer is piezoelectric (figure A1). The beam is clamped at  $x = 0$  and free at  $x = L$ ,  $x$  being the axial coordinate. The  $k$ th layer ( $k = 1, \dots, K$ ) is situated between heights  $z_{k-1}$  and  $z_k$ ,  $z$  being the bending direction; its thickness is  $h_k = z_k - z_{k-1}$  and its width (in the  $y$  direction) is  $b_k$ . A beam with a uniform cross section over its whole length  $L$  is considered. This allows evaluation of an equivalent single layer theory for the beam deformations, with the plane cross section remaining plane and orthogonal to the middle line (Euler–Bernoulli assumptions or classical theory of laminate composites [34]). The deformation of the beam in bending along  $z$  is characterized by the transverse displacement field along this direction  $w(x, t)$  at time  $t$  and axial position  $x$ , which is coupled to the voltage difference  $V(t)$  between the electrodes of the piezoelectric layer and the electric charge  $q(t)$  contained in its upper electrode. With this theory,  $w(x, t)$  obeys the following equation [30]:

$$\begin{cases} \widehat{D}w_{,xxx} + m\ddot{w} + \widehat{\Theta}[\delta(x-L)]_{,x} = 0, & \forall x \in [0, L] \\ q - \widehat{C}V - \widehat{\Theta}w_{,x}|_{x=L} = 0, \end{cases} \quad (\text{A.1})$$

where  $\widehat{D}$  is the bending stiffness of the beam,  $m$  is its mass per unit length,  $\widehat{\Theta}$  is the piezoelectric coupling coefficient,  $\widehat{C}$  is the blocked electric capacitance of the piezoelectric layer,  $\delta(x)$  is the Dirac delta function,  $(\cdot)_{,x} = \partial(\cdot)/\partial x$  and  $(\cdot) = \partial(\cdot)/\partial t$ . The electromechanical characteristics of the beam  $m, \widehat{D}, \widehat{\Theta}, \widehat{C}$  as a function of the geometrical/material properties of the layers are defined by:

$$\widehat{D} = D - \frac{B^2}{A}, \quad \widehat{\Theta} = \Theta - \frac{B}{A}\Xi, \quad \widehat{C} = C + \frac{\Xi^2}{AL}, \quad (\text{A.2})$$

with:

$$\begin{aligned} m &= \sum_{k=1}^K b_k h_k \rho_k, & A &= \sum_{k=1}^K b_k h_k Y_k, \\ B &= \sum_{k=1}^K b_k \frac{z_k^2 - z_{k-1}^2}{2} Y_k, & D &= \sum_{k=1}^K b_k \frac{z_k^3 - z_{k-1}^3}{2} Y_k, \end{aligned} \quad (\text{A.3})$$

$$\Xi = b_p Y_p d_{31}, \quad \Theta = b_p \frac{z_p + z_{p-1}}{2} Y_p d_{31}, \quad C = \epsilon_{33} \frac{b_p L}{h_p}, \quad (\text{A.4})$$

where  $Y_k$  and  $\rho_k$  are the Young’s modulus and the mass density of the  $k$ th layer,  $p$  is the index of the piezoelectric layer and  $d_{31}$  and  $\epsilon_{33}$  are its piezoelectric and dielectric constants.  $D, A, B$  are respectively the bending, axial and axial/bending stiffness parameters of the beam;  $\Theta, \Xi$  are the bending and axial piezoelectric parameters of the beam, respectively. The modified parameters that appear in equation (A.1), denoted with a hat ( $\widehat{D}, \widehat{\Theta}, \widehat{C}$ ), are independent of the vertical reference  $z = 0$  of the lamination, which can be chosen arbitrarily. It is also possible to choose the vertical reference so that  $B = 0$ , which in this case leads to  $\widehat{D} = D, \widehat{\Theta} = \Theta$  and  $\widehat{C} = C$ . The reader can refer to [30] for more details.

The eigenmodes of the beam in short circuit ( $V = 0$ ) are defined as follows. The natural frequencies, in [Hz], can be computed from:

$$f_k = \frac{\omega_k}{2\pi}, \quad \text{with } \omega_k = \frac{\beta_k^2}{L^2} \sqrt{\frac{\widehat{D}}{m}}, \quad (\text{A.5})$$

and the mode shapes are:

$$\begin{aligned} \Phi_k(\widehat{x}) &= \\ & \cos \beta_k \widehat{x} - \cos h \beta_k \widehat{x} + \frac{\sin \beta_k - \sin h \beta_k}{\cos \beta_k + \cos h \beta_k} (\sin \beta_k \widehat{x} - \sin h \beta_k \widehat{x}), \end{aligned} \quad (\text{A.6})$$

with  $\widehat{x} = x/L$ .  $\beta_k$  is the  $k$ th solution of:

$$\frac{1}{\cosh \beta} + \cos \beta = 0, \quad (\text{A.7})$$

because of the clamped – free boundary conditions, defined by:

$$\Phi_k(0) = 0, \quad \Phi_k'(0) = 0, \quad \Phi_k''(1) = 0, \quad \Phi_k'''(1) = 0, \quad (\text{A.8})$$

where  $(\cdot)' = d(\cdot)/d\widehat{x}$ . With equation (A.6), the mode shapes are naturally normalized:

$$\int_0^1 \Phi_k^2(\widehat{x}) d\widehat{x} = 1. \quad (\text{A.9})$$

With the above equations, the frequency parameters, the mode shape amplitude at the tip (the free end) and the slope at the same location are:

$$\begin{aligned} \beta_1 &= 1.8751, & \beta_2 &= 4.6941, & \beta_3 &= 7.8548, & \beta_4 &= 10.996 \\ \Phi_k(1) &= 2, & \forall k, \\ \Phi_1'(1) &= 2.7530, & \Phi_2'(1) &= 9.5616, & \Phi_3'(1) &= 15.697, \\ \Phi_4'(1) &= 21.990. \end{aligned} \quad (\text{A.10})$$

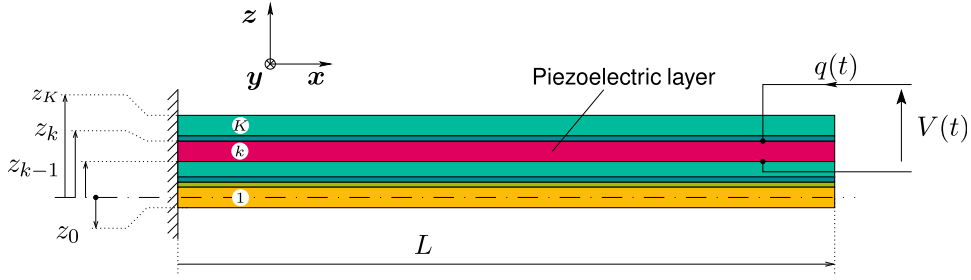
The equations of motion (A.1) are now expanded on the  $k$ th eigenmode:

$$w(x, t) = \Phi_k(x) \eta(t), \quad (\text{A.11})$$

where  $\eta(t)$  is the modal coordinate. Thanks to the orthogonality of the modes, the problem can be written as:

$$\begin{cases} \ddot{\eta} + \frac{\omega_k}{Q_k} \dot{\eta} + \omega_k^2 \eta - \frac{\chi_k}{mL} V = 0 \\ q = \widehat{C}V + \underbrace{\chi_k \eta}_{q_{\text{mot}}} \end{cases} \quad (\text{A.12})$$

with the modal piezoelectric coefficient defined by:



**Figure A1.** Sketch of the laminated cantilever beam composed of  $K$  layers.

$$\chi_k = \frac{\widehat{\Theta} \Phi'_k(1)}{L} \quad (\text{A.13})$$

and where a linear modal damping term has been added, of quality factor  $Q_k$ . The motional electric charge  $q_{\text{mot}}$ , defined in equation (A.12), is the part of the electric charge generated by the piezoelectric coupling.

For the frequency response of the cantilever beam, if a sine voltage  $V(t) = V_0 \cos \Omega t$  is applied across the piezoelectric layer, the modal coordinate and the motional electric charge are sine functions, that are written  $\eta(t) = \text{Re}(\widehat{\eta} \exp j\Omega t) = \eta_0 \cos(\Omega t + \varphi)$  and  $q_{\text{mot}}(t) = \text{Re}(\widehat{q}_{\text{mot}} \exp j\Omega t) = q_0 \cos(\Omega t + \psi)$ . With equation (A.12), the complex amplitudes  $\widehat{\eta} = \eta_0 \exp j\varphi$  and  $\widehat{q}_{\text{mot}} = q_0 \exp j\psi$  can be written:

$$\widehat{\eta}(\Omega) = \frac{\chi_k}{mL\omega_k^2 - \Omega^2 + 2j\omega_k\Omega/Q_k} V_0, \quad \widehat{q}_{\text{mot}}(\Omega) = \chi_k \widehat{\eta}(\Omega). \quad (\text{A.14})$$

Both  $\widehat{\eta}(\Omega)$  and  $\widehat{q}_{\text{mot}}(\Omega)$  display a resonant response as a function of  $\Omega$ .

The response of the cantilever at the resonance frequency,  $\Omega \approx \omega_k$ , is:

$$\eta_0 = \frac{\chi_k Q_k}{mL\omega_k^2} V_0, \quad q_0 = \frac{\chi_k^2 Q_k}{mL\omega_k^2} V_0, \quad (\text{A.15})$$

Considering the one-mode approximation of equations (A.11) and (A.13), the amplitude of the tip displacement at the  $k$ th resonance can be written:

$$w_{t0} = \Phi_k(1) \eta_0 = \frac{Q_k \widehat{\Theta} \Phi_k(1) \Phi'_k(1)}{mL^2 \omega_k^2} V_0. \quad (\text{A.16})$$

The motional capacitance, defined by the ratio of  $q_0$  and  $V_0$  at [31], is then:

$$C_{\text{mot}} = \frac{Q_k \widehat{\Theta}^2 \Phi_k'^2(1)}{mL^3 \omega_k^2} \quad (\text{A.17})$$

Comparing equations (A.2) and (A.4) shows that  $\widehat{\Theta}$  is proportional to  $Y_p d_{31}$ :

$$\widehat{\Theta} = \widehat{\Theta} Y_p d_{31}, \quad (\text{A.18})$$

with  $\widehat{\Theta}$  of dimension  $[\text{m}^2]$ . As a consequence, equations (A.16) and (A.17) can be rewritten:

$$\frac{w_{t0}}{V_0} = \frac{Q_k Y_p \widehat{\Theta} \Phi_k(1) \Phi'_k(1)}{mL^2 \omega_k^2} d_{31}, \quad C_{\text{mot}} = \frac{Q_k Y_p^2 \widehat{\Theta}^2 \Phi_k'^2(1)}{mL^3 \omega_k^2} d_{31}^2. \quad (\text{A.19})$$

The parameters  $\gamma$  (dimensionless) and  $\alpha$  (homogeneous to  $[\text{N/m}]$ ), depend on the geometrical and material properties of the beam (through parameters  $Y_p$ ,  $\widehat{\Theta}$ ,  $m$  and  $L$ ) and its  $k$ th eigenmode ( $\omega_k$ ,  $\Phi_k$ ,  $Q_k$ ).

## ORCID iDs

Daisuke Saya  <https://orcid.org/0000-0001-5414-9781>  
 Olivier Thomas  <https://orcid.org/0000-0001-7240-5259>  
 Susan Trolier-McKinstry  <https://orcid.org/0000-0002-7267-9281>

## References

- [1] Craighead H G 2000 Nanoelectromechanical systems *Science* **290** 1532–5
- [2] Roukes M L 2001 Nanoelectromechanical systems face the future *Phys. World* **14** 25–31
- [3] Ekinici K L 2005 Electromechanical transducers at the nanoscale: actuation and sensing of motion in nanoelectromechanical systems (NEMS) *Small J.* **1** 786–97
- [4] Yang Y T, Callegari C, Feng X L, Ekinici K L and Roukes M L 2006 Zeptogram-scale nanomechanical mass sensing *Nano Lett.* **6** 583–6
- [5] Chaste J, Eichler A, Moser J, Ceballos G, Rurali R and Bachtold A 2012 A nanomechanical mass sensor with yoctogram resolution *Nat. Nanotechnol.* **7** 301–4
- [6] Arlett J L, Myers E B and Roukes M L 2011 Comparative advantages of mechanical biosensors *Nat. Nanotechnol.* **6** 203–15
- [7] Ilic B, Yang Y, Aubin K, Reichenbach R, Krylov S and Craighead H G 2005 Enumeration of DNA molecules bound to a nanomechanical oscillator *Nano Lett.* **5** 925–9
- [8] Davis Z J *et al* 2003 Monolithic integration of mass sensing nano-cantilevers with CMOS circuitry *Sensors Actuators A* **105** 311–9
- [9] Karabalin R B, Matheny M H, Feng X L, Defay E, Le Rhun G, Marcoux C, Hentz S, Andreucci P and Roukes M L 2009 Piezoelectric nanoelectromechanical resonators based on aluminum nitride thin films *Appl. Phys. Lett.* **95** 103111
- [10] Sinha N, Wabiszewski G E, Mahameed R, Felmetser V V, Tanner S M, Robert W, Carpick R W and Piazza G 2009 Piezoelectric aluminum nitride nanoelectromechanical actuators *Appl. Phys. Lett.* **95** 053106
- [11] Qian Z, Liu F, Hui Y, Kar S and Rinaldi M 2015 Graphene as a massless electrode for ultrahigh-frequency piezoelectric nanoelectromechanical systems *Nano Lett.* **15** 4599–604
- [12] Nicu L and Leichlé T 2008 Biosensors and tools for surface functionalization from the macro- to the nanoscale: the way forward *J. Appl. Phys.* **104** 111101



- [13] Trolier-McKinstry S and Muralt P 2004 Thin film piezoelectrics for MEMS *J. Electroceram.* **12** 7–17
- [14] Lee C, Itoh T, Ohashi T, Maeda R and Suga T 1997 Development of a piezoelectric self-excitation and self-detection mechanism in PZT microcantilevers for dynamic scanning force microscopy in liquid *J. Vac. Sci. Technol. B* **15** 1559–63
- [15] Itoh T, Ohashi T and Suga T 2006 Piezoelectric cantilever array for multiprobe scanning force microscopy *IEEE Int. Conf. MEMS* pp 451–5
- [16] Mathieu F, Larramendy F, Dezest D, Huang C, Lavallee G, Miller S, Eichfeld C M, Mansfield W, Trolier-McKinstry S and Nicu L 2013 Reducing parasitic effects of actuation and sensing schemes for piezoelectric microelectromechanical resonators *Microelectron. Eng.* **111** 68–76
- [17] Guillon S, Saya D, Mazonq L, Costecalde J, Remiens D, Soyer C and Nicu L 2012 Lead zirconate titanate nanoscale patterning by ultraviolet-based lithography lift-off technique for nano-electromechanical system applications *IEEE Trans. Ultrason. Ferroelectr. Freq. Control* **59** 1955–61
- [18] Dezest D, Thomas O, Mathieu F, Mazonq L, Soyer C, Costecalde J, Remiens D, Deü J F and Nicu L 2015 Wafer-scale fabrication of self-actuated piezoelectric nanoelectromechanical resonators based on lead zirconate titanate (PZT) *J. Microelectron. Microeng.* **25** 35002–13
- [19] Welsh A J, Wilke R H T, Hickner M A and Trolier-McKinstry S 2013 Low-cost, damage-free patterning of lead zirconate titanate films *J. Am. Ceram. Soc.* **96** 2799–805
- [20] Saya D, Dezest D, Welsh A J, Thomas O, Mathieu F, Leichle T, Nicu L and Trolier-McKinstry S 2017 Fabrication and characterization of mechanical resonators integrating microcontact printed PZT films *Joint IEEE-Int. Symp. on the Applications of Ferroelectric (ISAF)/Int. Workshop on Acoustic Transduction Materials and Devices (IWATMD)/Piezoresponse Force Microscopy (Atlanta, USA, 7–11 May 2017)*
- [21] Arndt G, Defay E, Le Rhun G, Rey P, Perruchot F, Aid M, Liu L and Miller M 2010 Dynamic analytical modelling and piezoelectric characterization of a Pb(Zr,Ti)O<sub>3</sub>/SiN cantilever with losses *J. Micromech. Microeng.* **20** 115019
- [22] Yeo H G and Trolier-McKinstry S 2018 Effect of piezoelectric layer thickness and poling conditions on the performance of cantilever piezoelectric energy harvesters on Ni foils *Sensors Actuators A* **273** 90–7
- [23] Shepard J F Jr, Moses P J and Trolier-McKinstry S 1998 The wafer flexure technique for the determination of the transverse piezoelectric coefficient ( $d_{31}$ ) of PZT thin films *Sensors Actuators A* **71** 133–8
- [24] Fuentes-Fernandez E M A, Gnade B E, Quevedo-Lopez M A, Shah P and Alshareef H N 2015 The effect of poling conditions on the performance of piezoelectric energy harvesters fabricated by wet chemistry *J. Mater. Chem. A* **3** 9837–42
- [25] Lebid A, Necib B and Sahli M 2016 Analytical modeling of a piezoelectric bimorph beam *Am. J. Mech. Eng.* **4** 7–10
- [26] Kang L H, Lee D O and Han J H 2011 A measurement method for piezoelectric material properties under longitudinal compressive stress—a compression test method for thin piezoelectric materials *Meas. Sci. Technol.* **22** 065701
- [27] Costa C M, Sencadas V, Mano J F and Lanceros-Méndez S 2006 Effect of poling on the mechanical properties of  $\beta$ -poly(vinylidene fluoride) *Mater. Sci. Forum* **514–6** 951–5
- [28] Shepard J F Jr, Chu F, Kanno I and Trolier-McKinstry S 1999 Characterization and aging response of the  $d_{31}$  piezoelectric coefficient of lead zirconate titanate thin films *J. Appl. Phys.* **85** 6711–6
- [29] Kholkin A, Colla E, Brooks K, Muralt P, Kohli M, Maeder T, Taylor D and Setter N 1995 Interferometric study of piezoelectric degradation in ferroelectric thin films *Microelectron. Eng.* **29** 261–4
- [30] Ducarne J, Thomas O and Deü J F 2012 Placement and dimension optimization of shunted piezoelectric patches for vibration reduction *J. Sound Vib.* **331** 3286–303
- [31] Thomas O, Legrand B and Fuinel C 2015 Optimization of length and thickness of smart transduction layers on beam structures for control and M/NEMS applications *SMASIS 2015 (Colorado Springs USA, September 2015)* p 8857
- [32] Das D, Sanchez L, Martin J, Power B, Isaacson S, Polcawich R G and Chasiotis I 2016 Control of mechanical response of freestanding PbZr<sub>0.52</sub>Ti<sub>0.48</sub>O<sub>3</sub> films through texture *Appl. Phys. Lett.* **109** 131905
- [33] MakeItFrom.com 2018 Hafnia (Hafnium Oxide, HfO<sub>2</sub>) ([www.makeitfrom.com/material-properties/Hafnia-Hafnium-Oxide-HfO2](http://www.makeitfrom.com/material-properties/Hafnia-Hafnium-Oxide-HfO2))
- [34] Thomas O, Deü J F and Ducarne J 2009 Vibration of an elastic structure with shunted piezoelectric patches: efficient finite-element formulation and electromechanical coupling coefficients *Int. J. Numer. Methods Eng.* **80** 235–68
- [35] Miki H, Kushida-Abdelghafar K, Torii K and Fujisaki Y 1997 Degradation and recovery phenomena in Pb(Zr,Ti)O<sub>3</sub> capacitors with a platinum electrode *Japan. J. Appl. Phys.* **36** 1132–5
- [36] Reddy J N 1997 *Mechanics of Laminated Composite Plates and Shells: Theory and Analysis* (Boca Raton, FL: CRC Press)